Application Serial No: 10/768,940 Attorney Docket No.: 51890

Amendments to the Claims:

This listing of claims will replace all prior versions and listings of claims in the application:

Listing of Claims:

- 1. (Previously Presented) A negative-type photosensitive resin composition comprising an epoxy compound, poly(p-vinylphenol) and a phenol-biphenylene resin.
- 2. Canceled.
- 3. (Previously Presented) The negative-type photosensitive resin composition of claim 1, wherein the phenol-biphenylene resin is present in the range of 5 45 weight % based on the total weight of poly(p-vinylphenol) and phenol-biphenylene resin.
- 4. (Previously Presented) Method for the formation of a resist pattern, comprising the steps of coating a negative-type photosensitive resin composition on a substrate, wherein the composition comprises an epoxy compound, poly(p-vinylphenol) and a phenol-biphenylene resin; exposing the resin composition; and developing of the exposed composition to form the resist pattern.
- 5. (Previously Presented) The method of claim 4, wherein the developing comprises contacting the exposed composition with an aqueous alkaline solution.
- 6. (Previously Presented) The method of claim 4, wherein the exposing comprises exposing the resin composition to actinic radiation.
- 7. (Previously Presented) The negative-type photosensitive resin composition of claim
- 1, wherein the composition is developable in an aqueous alkaline solution.
- 8. (Previously Presented) The negative-type photosensitive resin composition of claim 1, further comprising an alkoxyalkylated melamine.
- 9. (Previously Presented) The method of claim 4, wherein the negative-type photosensitive resin composition further comprises an alkoxyalkylated melamine.
- 10. (Previously Presented) The method of claim 4, wherein the composition further comprises a photo-acid-generating agent.

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11. (Currently Amended) The <u>negative-type photosensitive resin composition method</u> of claim 1, wherein the composition further comprises a photo-acid-generating agent.